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The Composition and Photoelectrochemical Performance of Thin Films

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Deadline for manuscript submissions:

closed (31 December 2021)

Message from the Guest Editors

The main aim of this Special Issue is to serve scientists and engineers active in the fields of thin-film synthesis and its diagnostics, surface science, nanostructures (chemical composition, crystal phase) and finally their characterization (including composition photoelectrochemical performance) and applications. The scope of the Special Issue includes results of materials science, specific surface analytical techniques, theoretical and computational methods, the processing of films and nanostructures and applied physics. The deposition processes may include: pulsed laser deposition, physical and chemical vapour deposition, thermal and plasma spraying, thermo-chemical treatment, wet chemical and electrochemical processes such as plating, sol-gel coating, anodization, plasma electrolytic oxidation, etc., but excluding painting. Tribology and bio surfaces are not in the issue's scope. Special attention should be paid to the material response during its exposure to the whole solar spectrum or the particular wavelengths.













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Message from the Editor-in-Chief

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